

L Number	Hits	Search Text	DB	Time stamp
1	691	(buried near (oxide or dielectric or insulating) near (layer or film)) and (substrate near5 surface) and ((epi or epitaxy or epitaxial) near (film or layer))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/25 15:25
2	66	(buried near (oxide or dielectric or insulating) near (layer or film)) same (substrate near5 surface) same ((epi or epitaxy or epitaxial) near (film or layer))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/25 15:26
3	6	((buried near (oxide or dielectric or insulating) near (layer or film)) same (substrate near5 surface) same ((epi or epitaxy or epitaxial) near (film or layer))).clm.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/25 15:29
4	16	((buried near (oxide or dielectric or insulating) near (layer or film)) same (substrate near5 surface) same ((epi or epitaxy or epitaxial) near (film or layer)) same (semiconductor near (device or element)))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/25 15:30
5	13	((buried adj (oxide or dielectric or insulating) adj (layer or film)) same (substrate near2 surface) same ((epi or epitaxy or epitaxial) near (film or layer)) same (semiconductor near (device or element)))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/25 15:30
6	10	((buried adj (oxide or dielectric or insulating) adj (layer or film)) same (substrate near2 surface) same ((epi or epitaxy or epitaxial) adj (film or layer)) same (semiconductor near (body or device or element)))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/25 15:30
7	10	((buried adj (oxide or dielectric or insulating) adj (layer or film)) same (substrate near2 surface) same ((epi or epitaxy or epitaxial) adj (film or layer)) same (semiconductor adj (body or device or element)))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/25 15:32
8	0	((buried adj (oxide or dielectric or insulating) adj (layer or film)) same (substrate near2 ((first or second or top or bottom) adj surface)) same ((epi or epitaxy or epitaxial) adj (film or layer)) same (semiconductor adj (body or device or element)))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/25 15:33
9	2	((buried adj (oxide or dielectric or insulating) adj (layer or film)) same (substrate near2 ((first or second or top or bottom) adj surface)) same ((epi or epitaxy or epitaxial) adj (film or layer)))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/25 15:34

10	207	((oxide or dielectric or insulating) adj (layer or film)) same (substrate near2 ((first or second or top or bottom) adj surface)) same ((epi or epitaxy or epitaxial) adj (film or layer)))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/25 15:35
11	29	((oxide or dielectric or insulating) adj (layer or film)) near10 (substrate near2 ((first or second or top or bottom) adj surface)) near10 ((epi or epitaxy or epitaxial) adj (film or layer)))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/25 15:39
12	0	((oxide or dielectric or insulating) adj (layer or film)) near10 (substrate near2 ((first or second or top or bottom) adj surface)) near10 ((epi or epitaxy or epitaxial) adj (film or layer))) and (buried adj (oxide or insulating dielectric)).clm.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/25 15:37
13	0	((oxide or dielectric or insulating) adj (layer or film)) near10 (substrate near2 ((first or second or top or bottom) adj surface)) near10 ((epi or epitaxy or epitaxial) adj (film or layer))).clm. and (buried adj (oxide or insulating dielectric)).clm.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/25 15:37
14	0	((((oxide or dielectric or insulating) adj (layer or film)) near10 (substrate near2 ((first or second or top or bottom) adj surface)) near10 ((epi or epitaxy or epitaxial) adj (film or layer)))) and (buried near (oxide or dielectric or insulating)).clm.	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/25 15:38
15	2	((((oxide or dielectric or insulating) adj (layer or film)) near10 (substrate near2 ((first or second or top or bottom) adj surface)) near10 ((epi or epitaxy or epitaxial) adj (film or layer)))) and (buried near (oxide or dielectric or insulating))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2004/07/25 15:38